

Full paper

Two-dimensional metal phosphorus trisulfide nanosheet with solar hydrogen-evolving activity

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ABSTRACT

The development and utilization of photocatalysts to realize water-splitting without any external bias or sacrificial agents has received the limelight. As a novel two-dimensional layered material, metal phosphorus trichalcogenides (MPTs) cause wide research interest, presently. However, the growth of ultrathin two-dimensional MPT crystals is a great challenge to hinder their application. Here, we initially grow few-atomic layered nickel phosphorus trisulfide (NiPS₃) as promising photocatalyst for hydrogen evolution. The as-prepared NiPS₃ hexagonal nanosheet, as thin as few atomic layers (≤ 3.5 nm), has lateral size of larger than 15 μ m. These ultrathin NiPS₃ crystals can directly generate hydrogen gas from pure water without any sacrificial agents under sunlight. With ultraviolet photoelectron spectrometer and electrochemical impedance spectroscopy, we show that the attractive photocatalytic activity of the ultrathin NiPS₃ crystals arise from their appropriate positions of the band edges. This discovery is expected to make a contribution to develop next generation solar-fuel conversion catalysts for H₂ production.

1. Introduction

Generating hydrogen from water by utilizing solar energy is a potentially scalable approach to meet energy demand without any environmental crisis [1,2]. To date, various water-splitting methods are established for using the gigantic energy from the sun. A complicated photovoltaic electrolysis (PV) system, where the solar cell powers an electrolyzer, has been regarded as one of the efforts developed to realize the splitting of water. In some cases, additional supply of electrical power is required to assist the photocatalysis, namely photoelectrocatalysis, to derive the up-hill water splitting reaction. Compared with the above two methods, photocatalysis under mere irradiation of sunlight for water splitting is a much more facile approach [3]. But, in this system, the plentiful sacrificial agents usually have to be added in water to consume the photogenerated holes and boost the generation of hydrogen gas. Therefore, the solar-driven overall water splitting without the use of external bias or sacrificial agents is of particular interest due to its simplicity and low cost. During the past decades,

some single semiconductor based photocatalysts, such as nanocrystalline CoO [4] and (Ga_{1-x}Zn_x)(N_{1-x}O_x) solid solutions [5] were investigated for H₂ generation through water-splitting.

Recently, apart from these metal oxides, layered two-dimensional (2D) materials have received significant attention due to their unique chemical and physical features [6–9]. The 2D nature provides the possibility to reduce the electron-hole recombination via shortening the migration distance and increase the activity of interfacial reactions [10–12]. In this regard, the 2D structured g-C₃N₄ [13–16] has been proved as a promising photocatalyst under simulated solar light irradiation. Yet, its photoactivity for H₂ evolution is evaluated in the solution containing the sacrificial electron donor [13,17] or in the presence of co-catalysts [15,18,19]. So, the development of novel 2D nanomaterials capable of producing H₂ gas from pure water is highly desirable. Notably, metal phosphorus trichalcogenides (MPTs), a new kind of 2D semiconductors, are proposed [20,21] and theoretically studied [22] for water splitting nowadays. Their wide bandgaps from 1.3 eV to 3.5 eV endow them good photoelectronic properties and

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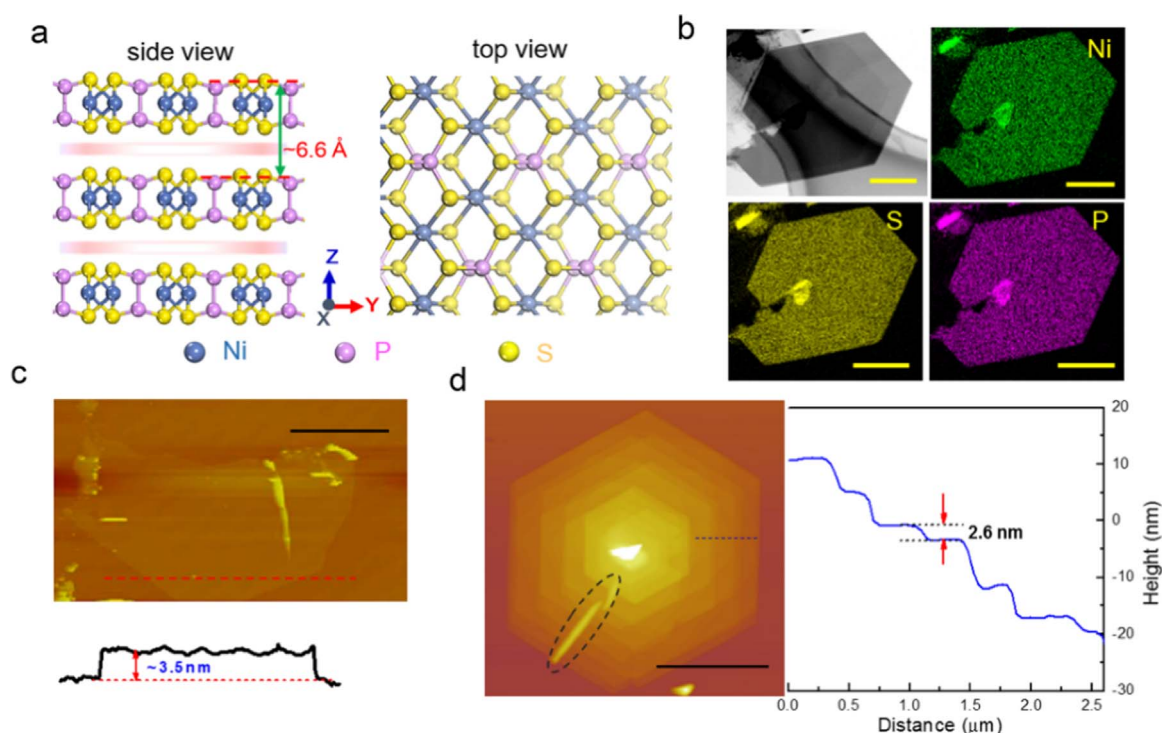


Fig. 1. (a) Schematic representation of typical NiPS₃ crystal structure from side and top view. (b) The EDX elemental mapping of Ni, S and P cross the hexagonal sheet. (c-d) AFM images and the corresponding height analysis of the hexagonal few layered and multilayered NiPS₃ crystals. Scale bar, (b) 500 nm and (c-d) 5 μ m.

photocatalytic activities. And their strong absorption in visible-light region and high carrier mobility ($625.9 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$ for MnPS₃) [22] suggest the potential ability for H₂ production under visible light. Unfortunately, only the bulk crystals of MPTs have so far been synthesized via the chemical vapor transport (CVT) process [21,23–25]. The method employs the heating of stoichiometric amount of high-purity elemental metal, phosphorus and sulfur powders in the evacuated quartz tube at high temperature ($> 600^\circ \text{C}$) for couple of days. As to the nanostructured MPTs, it has remained a great challenge to successfully make the synthesis and hence there has been no report about the nanoscale growth of such materials hitherto.

Here, we develop a chemical vapor deposition (CVD) process with the mixed sulfur and phosphorus powder as well as various substrates grown Ni(OH)₂ nanosheets to initially grow ultrathin 2D hexagonal nickel phosphorus trisulfide (NiPS₃) crystals in large area. The resulting NiPS₃ nanosheet can be as thin as a few atomic layers, with the lateral sizes up to a dozen of micrometers ($> 10 \mu\text{m}$) and high crystalline quality. This crystal comprises covalently bonded (P₂S₆)⁴⁻ bipyramids, located in the center of six nearby Ni²⁺, and the layers stack in C2/m space group via van der Waals force (Fig. 1a). One single-layer has the thickness around 0.66 nm. Significantly, these NiPS₃ nanosheets can decompose pure water to produce hydrogen gas under Xe light ($\lambda > 300 \text{ nm}$) and simulated solar light without any co-catalysts or sacrificial agents. The H₂ evolution rate under Xe light and simulated solar light is about 26.42 and 6.46 $\mu\text{mol/g/h}$, respectively. Using ultraviolet photoelectron spectrometer and electrochemical impedance spectroscopy, we show that the attractive photocatalytic activity of the 2D ultrathin NiPS₃ crystals arise from their appropriate positions of the band edges. To the best of our knowledge, this work is the first to communicate the facile synthesis of ultrathin NiPS₃ crystals and demonstrate its photocatalytic activity.

2. Experimental section

2.1. CVD growth of 2D ultrathin NiPS₃ crystals

Firstly, the ultrathin Ni(OH)₂ nanosheets were prepared on the carbon fibers (CFs), fluorine doped tin oxide (FTO) and indium tin oxide (ITO) glasses with the size of $2 \times 4 \text{ cm}^2$ through the typical hydrothermal method (Supporting information) [26]. The tube furnace with two zones was used in the growth (Fig. S1). The CFs or FTO glasses grown Ni(OH)₂ nanosheets were then put in a quartz tube to act as the growth substrates, located in the right zone (downstream) of the furnace, for the growth of 2D ultrathin NiPS₃ crystals (Fig. S1). Appropriate amount (1.0 g) of highly purified phosphorous (red phosphorus, 98.5%) and sulfur powders (99.5%) with the molar ratio of $n_{\text{P}}:n_{\text{S}} = 2:5$ were grinded together and kept on the left zone (upstream) in another quartz tube. The distance between right zone and left zone is $\sim 26 \text{ cm}$. Subsequently, the right and left zones were simultaneously heated to $\sim 470^\circ \text{C}$ and $\sim 270^\circ \text{C}$ within 30 min under Ar gas (20 sccm, 99.999%), respectively. The reaction lasted to 60 min at 470°C . To ensure the completed reaction, the mixture of P and S powder was finally heated to 300°C . Before each growth, oxygen was carefully removed through a repeated purging (with Ar gas, 99.999%) and pumping process until the pressure down to 0.1 Pa. After the growth, the samples were cooled to room temperature and protected in a small serum bottle filled with argon gas (99.999%) for further measurements.

2.2. Structural characterization

The morphology of the ultrathin NiPS₃ crystals was identified by scanning electron microscopy (SEM, Hitachi S4800), the thickness by atomic force microscopy (AFM, MFP-3D Infinity), and the chemical composition, crystalline quality and detailed crystal structure by transmission electron microscopy (TEM, FEI Tecnai F20, 200 kV for selected area electron diffraction (SAED) measurement and HRTEM observations; JEM-2100F, 200 kV for STEM- energy dispersive X-ray spectroscopy (EDX) elemental mapping and EDX spectra). Atomic-level

HAADF-STEM images were obtained from a 300 kV STEM (JEM ARM200F). X-ray diffraction (XRD, D/MAX-TTRIII (CBO) diffractometer) using Cu K α radiation ($\lambda = 1.5418 \text{ \AA}$) was used to check the crystal structure. Raman scattering was performed on a confocal microscope-based Raman spectrometer (Renishaw InVia) in ambient air environment with an excitation laser line of 532 nm. X-ray photo-emission spectra (XPS) were recorded on ESCALAB 250 Xi system of Thermo Scientific, where the analysis chamber was 1.5×10^{-9} Mbar and the X-ray spot was 500 μm . The valence band energy of the NiPS₃ crystals were analyzed on Thermo Scientific ESCALAB 250Xi using ultraviolet photoelectron spectroscopy (UPS). The gas discharge lamp was used for UPS, with helium gas admitted and the HeI (21.22 eV) emission line employed. The helium pressure in the analysis chamber during analysis was about 2E^{-8} mbar. The data were acquired with -10 V bias. Room temperature UV–Vis diffuse reflectance spectra was recorded using a Lambda 750 spectrophotometer in the wavelength range of 400–1000 nm.

2.3. Electrochemical impedance measurement

In order to measure the band edge positions (or flatband potentials) of ultrathin NiPS₃ crystals, a piece of carbon fibers (CFs) grown NiPS₃ acted as working electrode in typical three-electrode system with the platinum wire as a counter electrode and SCE as a reference electrode. The measured area of the working electrode was $\sim 1 \text{ cm}^2$. The electrolyte was 0.1 M Na₂SO₄ solution (pH = 6.59). Electrochemical impedance spectroscopy (EIS) measurements were carried out using a Princeton Applied Research (PAR) Potentiostat/ Galvanostat VersaSTAT3. Both the potentiostat and the lock-in amplifier were controlled by a computer using VersaStudio software. The potential was scanned between 0.0 and 2.1 V with various modulation frequencies. All the potentials reported here are relative to RHE. Potential conversion between SCE and RHE is given by: $E (\text{vs RHE}) = E (\text{vs SCE}) + 0.242 \text{ V} + 0.059 \times \text{pH}$.

2.4. Photocatalytic activity test

The photocatalytic reactions of the photocatalysts were carried out in an outer irradiation-type photoreactor (Pyrex glass) connected to a closed gas-circulation system. The NiPS₃ nanosheets covered carbon fibers with the size of $\sim 8 \text{ cm}^2$ (the mass loading of NiPS₃ crystals about 1.25–1.88 mg/cm²) were directly immersed in 100 mL ultrapure water (Millipore, 18.2 Ω). A 300 W Xe-lamp and a cutoff filter was applied to achieve AM 1.5G solar simulator. The photocatalytic H₂ evolution rate was analyzed using an on-line GC-7900 gas chromatograph (GC, TCD detector, 5A molecular sieve column and Ar carrier). Magnetic stirrer was used during the water splitting experiment to ensure the gas release. The catalyst was used for continuous water splitting up to one day.

2.5. Theoretical calculations

The spin-polarized calculations on the bulk and slab NiPS₃ were both performed by adopting the Vienna *ab-initio* simulations package (VASP) code [27]. The interaction between ions and electron was described by the project augmented wave (PAW) [28]. And the generalized gradient approximation (GGA) expressed by the functional of Perdew, Burke and Ernzerhof (PBE) [29]. A cutoff energy was set to 500 eV for structure optimization and electronic structure calculation. The single-layer NiPS₃ was cleaved from the (001) crystal face of bulk NiPS₃ and modeled by a 2×2 supercell. Thus an 8% S vacancy concentration (close to the experiment value 7%) can be obtained by removing two S atoms. A Monkhorst-Pack mesh of $9 \times 9 \times 1$ was used for slab model and $6 \times 3 \times 5$ for the bulk. In addition, a vacuum space with 15 \AA was inserted between the adjacent NiPS₃ sheets. During geometry optimization, all the atoms were fully relaxed until the

residual forces were less than 0.02 eV/ \AA .

3. Results and discussion

We synthesized 2D ultrathin NiPS₃ crystals with a high density via simple chemical vapor deposition (CVD) method (Fig. S1) starting from the Ni(OH)₂ nanosheets (Fig. S2) [26], elemental sulfur and phosphorous precursors. The relatively mild reaction condition at 450–470 °C enables the growth of NiPS₃ nanosheets on various substrate, including carbon fibers (CFs), fluorine doped tin oxide (FTO) and indium tin oxide (ITO) glasses (Fig. S3). At the beginning, small irregular nanosheets with the size below 500 nm were formed (Fig. S4a). A longer growth time led to the increase in the size and the change in morphology of the nanosheets (Fig. S4b–c). At a lower growth temperature ($\leq 400 \text{ }^\circ\text{C}$), the reaction would be not finished and the nanosheet had relatively smaller size along with lots of residual reactant (Fig. S5a). But, when the growth temperature was brought above 500 °C, the NiPS₃ nanosheets would be converted to the “squamae” (Fig. S5c–f) due to the etching process at high temperature [30]. Therefore, we used the growth temperature of 450–470 °C to fabricate hexagonal NiPS₃ crystals (Fig. S4c and Fig. S5b) within 60 min. After CVD growth, the ultrathin 2D NiPS₃ crystals can be transferred to SiO₂/Si substrate or TEM grids for detailed structural characterization and measurements. Fig. 1b shows a low-magnification annular dark-field TEM image of a hexagonal 2D crystal. The EDX and corresponding EDX mapping indicates the crystal is composed of homogeneous Ni, P and S distribution with the atomic ratio of $\sim 1:1:3$ (Fig. S6).

The ultrathin NiPS₃ nanosheet, transferred onto SiO₂/Si substrate, has the thickness of $\sim 3.5 \text{ nm}$ and lateral size of $\sim 15 \mu\text{m}$ as can be seen from AFM image in Fig. 1c. Interestingly, AFM image (Fig. 1d) of some complete NiPS₃ hexagon clearly exhibits the spiral structure topology because of the introduction of a “pike” from the residue of precursor at initial stage (Fig. S7) [31–33]. It consists of multilayered hexagons with the thickness of each layer down to $\sim 2.6 \text{ nm}$. The structure of NiPS₃ crystals was further studied with XRD pattern. The sharp peaks in Fig. 2a can be attributed to the monoclinic NiPS₃ (PDF No.33-0952). The Raman spectrum, excited by 532 nm laser light, of the NiPS₃ nanosheets on CFs is investigated in Fig. 2b. The first-order modes, including four in-plane E_g (~ 130 , ~ 175 , ~ 281 and $\sim 555 \text{ cm}^{-1}$) and two out-of-plane A_{1g} (~ 381 and $\sim 585 \text{ cm}^{-1}$) phonon modes, dominate the spectrum [25,34]. Fig. 2c shows the XPS spectra (Fig. S8) of NiPS₃ nanosheets in Ni2p, P2p and S2p regions. The binding energy of Ni2p_{3/2} ($\sim 854.54 \text{ eV}$) and the present shake-up satellites features further confirm the NiPS₃ chemical nature [35]. The prominent P2p peaks at 131.98 eV (2p_{3/2}) and 132.80 eV (2p_{1/2}) are assigned to covalent P-S. The S2p_{3/2} and S2p_{1/2} peaks, located at $\sim 162.50 \text{ eV}$ and $\sim 163.62 \text{ eV}$, respectively, are attributed to Ni-S and P-S [35,36]. It is of particular note that there is a slightly red shift in the binding energy for P2p_{3/2} and S2p_{3/2} peaks compared to those (~ 132.32 and $\sim 163.1 \text{ eV}$) of bulk crystal [35], which is resulted from the presence of sulfur vacancy in the sample. More about this will be discussed later.

The crystallographic structure and quality of NiPS₃ nanosheet was further characterized by high-resolution TEM (HRTEM), selected-area electron diffraction (SAED) and scanning transmission electron microscopy (STEM). Fig. 3a clearly demonstrates the hexagonal morphology of the ultrathin 2D NiPS₃ crystal with the lateral size of $\sim 8 \mu\text{m}$. The SAED pattern (Fig. 3b) along the [001] zone axis indicates the high crystallinity of the nanosheet. Additionally, a series of planes and relevant angles marked in the SAED pattern further reveal the monoclinic crystal system (PDF No.33-0952). Moreover, HRTEM image of the NiPS₃ ultrathin crystal shows a honeycomb arrangement of the atoms with the lattice spacing of 0.267 nm and 0.252 nm, corresponding to the (022) and (040) planes (Fig. 3c). The direct observation of the atoms on the basal plane is achieved through typical atomic-level high-angle annular dark-field (HAADF)-STEM image owing to the contrast obtained by the presence and the nature of the atoms under the electron

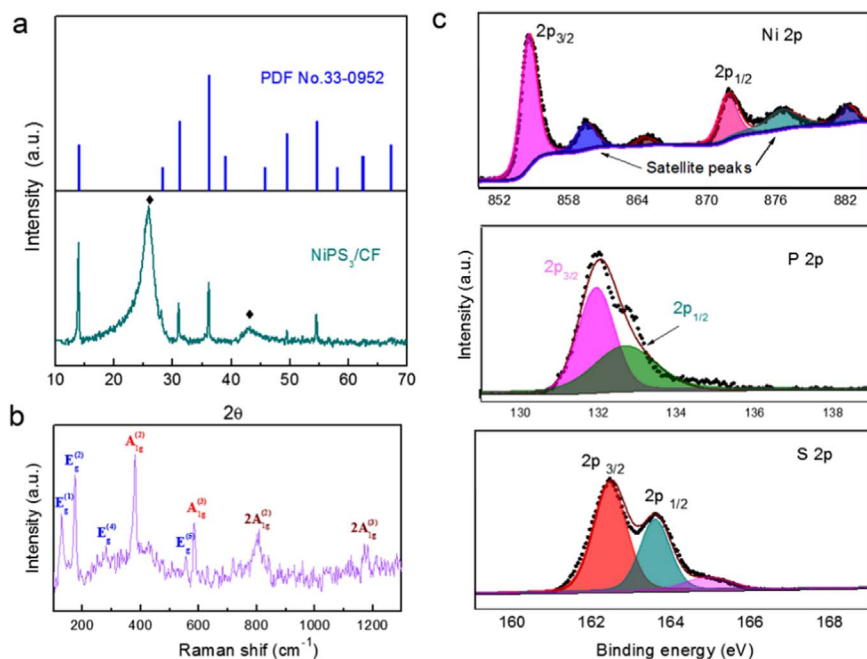


Fig. 2. (a-b) XRD pattern ("♦" stands for the XRD pattern from CFs) and Raman spectrum of NiPS₃ on the CFs. (c) XPS analysis in Ni 2p, P 2p and S 2p regions, respectively.

beam. As shown in Fig. 3d, inside the basal plane (001) per [P₂S₆] unit is found in the center of nearby six Ni atoms, exhibited by brightest spots. The S and P atoms can't be distinguished clearly because their molar mass is very close to each other. The atom arrangement is consistent with the crystal structure in Fig. 1a. Of particular note is that some S vacancies (S_v) are observed in the NiPS₃ nanosheet (Fig. 3e-f), similar with the S vacancies observation in MoS₂ nanosheet [37–39]. Careful analysis of the NiPS₃ basal plane reveals that the S vacancies is estimated as ~7.6% (Fig. S9). This phenomenon is also consistent with the XPS analysis and gives rise to the ferromagnetism features (Fig. S10, S11 and Note SII).

Water-splitting experiments were performed in an air-tight flask with 2D ultrathin NiPS₃ crystals on CFs in neutral pure water under

Xenon light or simulated AM1.5G solar illumination (Fig. 4a). The sign of generated H₂ was quantified by gas chromatography (GC) trace using argon as the carrier gas (inset of Fig. 4a). And there is no quantifiable oxygen gas in this photocatalytic system (the detail discussion is in Note SI). As displayed in Fig. 4b, the generation of H₂ is observed when the system is kept under the Xenon light (λ > 300 nm). The H₂ evolution proceeds continuously with the constant rate of ~26.42 μmol/g/h until turning off the light irradiation. As comparison, control experiment unveils that almost no O₂ is detected when AgNO₃ used as the sacrificial hole donor under the same condition (Supporting information). Nevertheless, when the Na₂S/ Na₂SO₃ as sacrificial electron donor, H₂ could be produced with the rate of 74.67 μmol/g/h (Supporting information, Fig. S12). These results suggest the NiPS₃ nanosheets are not

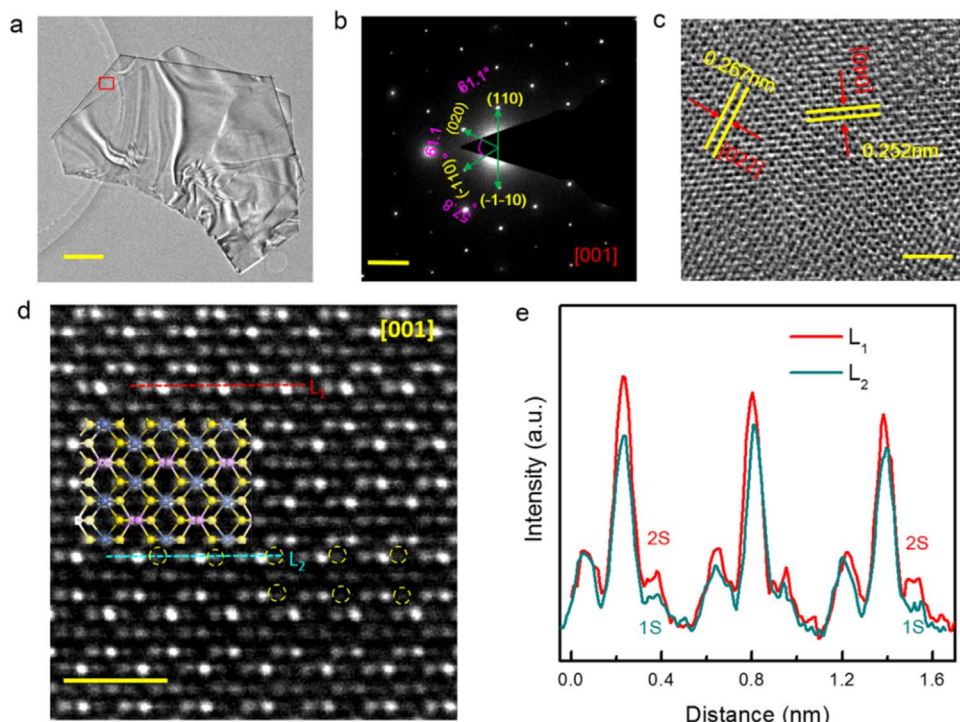


Fig. 3. (a-c) Low-magnification TEM image, SAED pattern along the [001] zone axis and HRTEM image marked in a of a hexagonal 2D NiPS₃ crystal. (d) Atomic-level HAADF-STEM image of an ultrathin NiPS₃ nanosheet showing the sulfur vacancies (yellow circles) and the corresponding structural schematic. FFT mask filter has been employed for clarity. (e) Intensity profiles along lines L1-L2. Higher contrast is obtained from the Ni atom compared to S atom. In absence of S atoms in this NiPS₃ nanosheet (L2), the intensity decreases to < 50% compare with the intensity in L1. Scale bar, (a) 1 μm, (b) 2 1/nm, (c) 2 nm and (d) 1 nm.

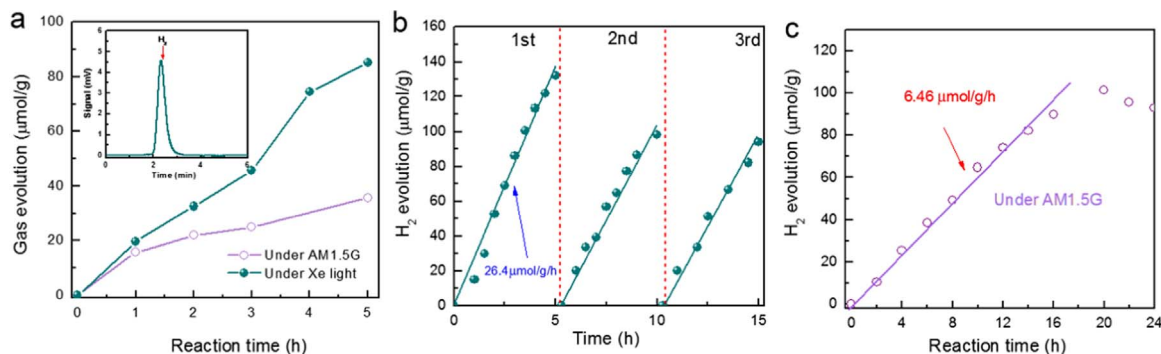


Fig. 4. (a) The comparison of H_2 production from pure water under different light irradiation. Inset: a typical gas chromatogram (GC) trace of evolved hydrogen gas after 10 h with irradiation of Xe-Light. (b–c) Time course of H_2 production from pure water under Xe light and AM 1.5G simulator within different irradiation time.

suitable for oxygen evolution under the irradiation of Xenon light. With the aim of extending the scenario towards more realistic phenomena, the photocatalytic experiment was conducted under illumination of simulated solar light and significant generation of H_2 gas is observed in this condition too (Fig. 4c). The constant H_2 evolution rate is $\sim 6.46 \mu\text{mol/g/h}$. The superior stability, which turns out to be stable in continuous 20-h test, further indicates the promising practical potential (Fig. S13 and S14). These results corroborate the photocatalytic ability of the 2D NiPS_3 crystals to generate H_2 gas from pure water without any sacrificial agent.

To understand the catalytic activity of the 2D NiPS_3 crystals and explore the reason why the stoichiometric oxygen gas could not be released in this system, we further studied the band structure [4]. Fig. 5a shows the reflectivity spectrum of the sample. The corresponding optical bandgap can be estimated from the modified Kubelka-Munk function $((ah\nu)^r \text{ vs } h\nu)$, the inset of Fig. 5a).

A good linear fit when using $r = 1/2$ is in accord with the previously calculated work [22] claiming NiPS_3 to be an indirect bandgap material. The bandgap (E_g) is close to 1.96 eV, a value similar to that reported in the literature [40,41]. To obtain absolute band-edge positions with respect to water redox potentials, we utilize the NiPS_3 on CFs as an electrode to measure its flat-band potentials [42–44]. From the Mott-Schottky plots (Fig. 5b), the flat-band potential of 0.81 V, the difference between Fermi level and water-reduction potential, is observed. Negative slopes of the Mott-Schottky plots indicate that the NiPS_3 is a p -type semiconductor. A similar result was observed elsewhere [45]. Here, we assumed that Fermi level is about 0.3 eV above the valence band for p -type semiconductors [43,46]. The valence band position is thus estimated at 1.11 V (vs RHE, $-5.55 \text{ eV vs } E_{\text{vacuum}}$). Furthermore, ultraviolet photoelectron spectroscopy (UPS) was also used to determine the valence band energy level

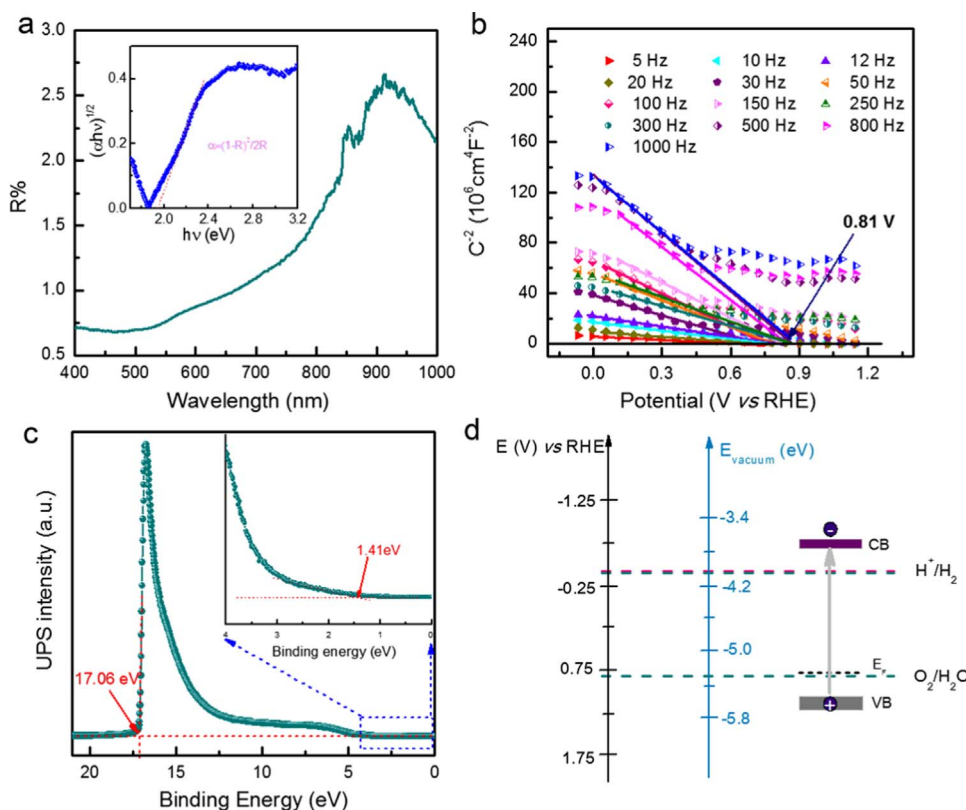


Fig. 5. (a) Ultraviolet–visible diffuse reflectance spectrum and the corresponding $((ah\nu)^{1/2} \text{ vs } h\nu)$ as a function of photon energy ($h\nu$), where a is the Kubelka-Munk function of the diffuse reflectance R . The intercept of extrapolated straight line give the bandgap of NiPS_3 crystals. (b) Mott-Schottky plots for NiPS_3 nanosheets according to impedance measurements. The flat-band potential (0.81 V vs RHE) is achieved from the intercept of the extrapolated lines. (c) UPS spectra of NiPS_3 crystals, in which the dashed red lines mark the baseline and the tangents of the curve. The intersections of the tangents with the baseline give the edges of the UPS spectra based on the UPS width. (d) Band structure diagram for NiPS_3 nanosheets according to the bandgap, flat-band potential and UPS edges obtained from (a–c). VB, valence band; CB, conduction band.

of NiPS₃ crystals. The value is calculated to be -5.57 eV (vs E_{vacuum}), in agreement with the value from the M-S plot, by subtracting the width of He I UPS spectra (Fig. 5c) from the excitation energy (21.22 eV). The conduction band energy (E_c) is then calculated as ~ -3.61 eV from E_v - E_g . A more obvious illustration is given in Fig. 5d comprising of the above discussed band edge energy positions. As can be seen, the conduction band of the ultrathin NiPS₃ crystals is situated above the water reduction potential which is a thermodynamically feasible level for generating H₂ gas. In so far the valence band is concerned, it is slightly below the oxidation level of H₂O to O₂ (-5.28 eV). Here comes the reason why there is no evolution of O₂ gas in our photocatalytic system. A weak intrinsic driving force in band alignment of ultrathin 2D NiPS₃ crystals with water oxidation potential is not energetically sufficient to supply the required holes for the generation of oxygen gas. As with many single-component photocatalysts, ultrathin NiPS₃ nanosheets likewise suffer from the issue of stability-their activity reduces by half after about a one-day of reaction (Fig. 4b and d). The morphology and crystallinity of the 2D ultrathin NiPS₃ crystals still retained after a long time reaction (Fig. S11), suggesting their stability is still better than that of nanocrystalline CoO photocatalyst [4]. The negligible change in the XPS spectra in Ni 2p region suggests the stability of NiPS₃ nanosheets during the long-time reaction (Fig. S14b). While, the XPS spectra in P 2p and S 2p regions demonstrate shifts of ~ 0.34 eV (Fig. S14c-d) to higher binding energy, which is due to the strong oxygen adsorption on the P and S atoms. And the XPS spectra in O 1s region indicate that the surface of the NiPS₃ is slightly oxidized after photocatalytic test (Fig. S15). As a matter of concept, DFT calculations about absorption energy of O atoms on the surface of NiPS₃ (Fig. S16) corroborates the observed surface oxidation. There exists the strong interaction between P or S sites, located around S_v position, and O atoms. In addition to the energy barrier issue for incapability of O₂ evolution in our photocatalytic experiment, the presence of S_v plays its own role in strongly adsorbing oxygen intermediate species thereby suppressing the generation of O₂ gas (Supporting information).

The present photocatalysis offers a simpler and lower-cost approach to quantitatively extract pure H₂ gas from neutral water in quantity. Even more attractively, the catalyst in this photocatalytic system avoids the complicated step to separate pure H₂ gas from the explosive gas mixture, containing hydrogen and oxygen, directly achieved through the overall water splitting [3]. However, further investigation is indeed needed to unveil a clear picture of the surface chemistry and lattice structure of the atomic-layered NiPS₃ crystals regarding the oxidation products. We believe that, with further research, the photocatalytic activity can be improved under sunlight, for instance, via separating the oxidation products from their surface or integrating NiPS₃ nanosheets with suitable co-catalysts [47]. The construction of a highly active photocatalysts based on 2D ultrathin NiPS₃ crystals paves a way to develop practical solar fuel applications and acquire new microscopic insights into photocatalytic water-splitting. Consequently, our discovery is expected to make a contribution to develop next generation solar-fuel catalysts for H₂ production.

4. Conclusions

In summary, we, for the first time, grow ultrathin two-dimensional NiPS₃ nanosheets through CVD method on different substrates. The thickness of the hexagonal NiPS₃ nanosheets, whose lateral size is larger than $15\ \mu\text{m}$, is about few atomic layers (≤ 3.5 nm). Significantly, these NiPS₃ nanosheets can be directly utilized as a novel photocatalyst to split water for hydrogen evolution under solar lights irradiation without any co-catalyst and sacrificial agents. The band structure of the 2D ultrathin NiPS₃ was systematically studied via using ultraviolet photoelectron spectrometer and electrochemical impedance spectroscopy. The appropriate position of the band edge is crucial for photocatalytic

water splitting. Our discovery opens a new avenue to develop next generation solar-fuel catalysts for H₂ production.

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Appendix A. Supporting information

Supplementary data associated with this article can be found in the online version at <http://dx.doi.org/10.1016/j.nanoen.2017.09.017>.

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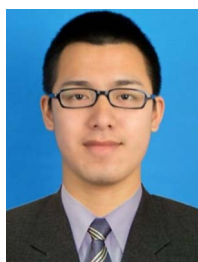
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